PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

KAWABE, YASUMASA, et al.

Appln. No.: 09/295,329

Filed: April 21, 1999

POSITIVE PHOTOSENSITIVE RESIN COMPOSITION

Examiner: Clarke, Y.

SITIVE PHOTOSENSITIVE RESIN COMPOSITION

PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R. § 1.136

Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

For:

Pursuant to 37 C.F.R. § 1.136, Applicants hereby petition for an extension of time of one month, extending the time for responding to the Office Action of May 19, 2000 to September 19, 2000.

A check for the statutory fee of \$110.00 is attached. Please charge any additional fees under 37 C.F.R. § 1.16 or § 1.17 necessary to keep this application pending in the Patent and Trademark Office or credit any overpayment to Deposit Account No. 19-4880. A duplicate copy of this sheet is enclosed.

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Date: September 19, 2000

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